

United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/942,036	08/30/2001	Junji Tominaga	325772026700	7287
25227	7590 10/05/2004		EXAMINER	
MORRISON & FOERSTER LLP 1650 TYSONS BOULEVARD			ORTIZ CRIADO, JORGE L	
SUITE 300 MCLEAN, VA 22102			ART UNIT	PAPER NUMBER
		2655		

DATE MAILED: 10/05/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)			
		09/942,036	TOMINAGA ET AL.			
	Office Action Summary	Examiner	Art Unit			
		Jorge L Ortiz-Criado	2655			
The MAILING DATE of this communication appears on the cover sheet with the correspondence address						
Period for Reply						
THE N - Exter after - If the - If NO - Failui Any r	ORTENED STATUTORY PERIOD FOR REPLY MAILING DATE OF THIS COMMUNICATION. Insions of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. Period for reply specified above is less than thirty (30) days, a reply in period for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be ting within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).			
Status *						
1)	Responsive to communication(s) filed on <u>15 June 2004</u> .					
•		action is non-final.				
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims						
⊿\⊠	4)⊠ Claim(s) <u>1-4</u> is/are pending in the application.					
	4a) Of the above claim(s) is/are withdrawn from consideration.					
	Claim(s) is/are allowed.					
	☐ Claim(s) is/are anowed. ☐ Claim(s) is/are rejected.					
	Claim(s) is/are objected to.					
8)	Claim(s) are subject to restriction and/o	or election requirement.				
Applicati	ion Papers					
• •	The specification is objected to by the Examine	er.				
,	10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.					
. • ,	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).					
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11)[The oath or declaration is objected to by the Ex					
Priority (under 35 U.S.C. § 119					
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a) ☐ All b) ☐ Some * c) ☐ None of:						
,	1. Certified copies of the priority documents have been received.					
	2. Certified copies of the priority documents have been received in Application No					
	3. Copies of the certified copies of the priority documents have been received in this National Stage					
	application from the International Bureau (PCT Rule 17.2(a)).					
* See the attached detailed Office action for a list of the certified copies not received.						
Attachment(s)						
· ===	ce of References Cited (PTO-892)	4) 🔲 Interview Summar Paper No(s)/Mail [
3) Infor	ce of Draftsperson's Patent Drawing Review (PTO-948) rmation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) er No(s)/Mail Date	_,	Patent Application (PTO-152)			

Application/Control Number: 09/942,036

Art Unit: 2655

DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims 1-4 are rejected under 35 U.S.C. 102(b) as being anticipated by Izumi et al. U.S. patent No. 5,610,985.

Regarding claim 1, Izumi et al. discloses an apparatus for reproducing information stored in an optical recording medium which comprises marks or pits which are arranged at a pitch less than λ /2NA, wherein λ is a wavelength of light used for reproduction and NA is an numerical aperture of an objective lens (See col. 1, lines 10-15, col. 2, lines 4-14; Fig. 4; Fig. 10), said apparatus comprising:

a shielding band which is located in an optical path of an optical system for detecting light coming from the optical recording medium in such a position to shield at least a middle of a bundle of rays (See col. 2, line 58 to col. 3, line 10; col. 3, line 65 to col. 4, line 30; Fig. 4, ref# 5; Fig. 6A; Fig.10; ref#25B)

Application/Control Number: 09/942,036

Art Unit: 2655

Regarding claim 2, Izumi et al. discloses an apparatus for reproducing information stored in an optical recording medium which comprises marks or pits which are arranged at a pitch less than $\lambda/2NA$, wherein λ is a wavelength of light used for reproduction and NA is an numerical aperture of an objective lens (See col. 6, line 38 to col. 7, line 20; Fig. 10), said apparatus comprising:

a first detecting system for generally detecting optical signals from marks or pits which are arranged at a pitch not less than λ 2NA (See col. 6, line 38 to col. 7, line 20; Fig. 10-"39");

a second detecting system for generally detecting optical signals from marks or pits which are arranged at a pitch less than λ 2NA (See col. 6, line 38 to col. 7, line 20; Fig. 10-"42", "43"); and

a signal processing circuit for reproducing information by combining the signals detected by the first detecting system with the signals detected by the second detecting system (See col. 6, line 38 to col. 7, line 20 "signal detection system").

Regarding claim 3, Izumi et al. discloses wherein the second detecting system comprises a shielding band for shielding at least a middle of a bundle of rays (See col. 6, line 38 to col. 7, line 20; Fig. 10-"25B)

Regarding claim 4, Method claim 4 is drawn to the method of using the corresponding apparatus claimed in claim 2 or 3. Therefore method claim 4 corresponds to the apparatus claim 2 or 3 and is rejected for the same reason of anticipation as used above.

Art Unit: 2655

3. Applicant's arguments filed 06/15/2004 have been fully considered but they are not

persuasive.

Applicants argue that Izumi fails to teach or suggest the feature "mark or pits arranged at a pitch less than $\lambda/2NA$ ".

The Examiner cannot concur because Izumi does not expressly disclose "a pitch less than λ 2NA". Applicant acknowledged that Izumi discloses "High density recording in a recording medium".

Izumi also discloses an apparatus for reproducing information stored in an optical recording medium, which comprises marks or pits of a "super-resolution" recording medium (see col. 2, lines 5-14; Fig. 3, ref# 50, Fig. 6, ref# 50).

The mark or pits arranged at a pitch less than λ 2NA is well known as a "super – resolution" optical disk. In page 1, paragraph [004], Applicant's admitted prior art, clearly states that a recording medium having mark or pits arranged at a pitch less than λ 2NA, is merely a super-resolution optical disk.

Applicants argue that Izumi fails to teach or suggest the feature of the second detecting system comprises a shielding band for shielding at least a middle of a bundle of rays.

The Examiner cannot concur because Izumi discloses wherein the layer 25B is similar to the shielding portion 5B, which shields the bundles of rays of the second detecting system (Fig. 10-"42", "43") Hence, the middle bundle of rays is shielded. (See col. 6, line 38 to col. 7, line 20 Fig. 4, ref# 5; Fig. 6A; Fig.10; ref#25B)

Application/Control Number: 09/942,036

Art Unit: 2655

Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jorge L Ortiz-Criado whose telephone number is (703) 305-8323. The examiner can normally be reached on Mon.-Thu.(8:30 am - 6:00 pm), Alternate Fridays off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Doris H To can be reached on (703) 305-4827. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Art Unit: 2655

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

joc

WILLIAM KORZUCH
SUPERVISORY PATENT EXAMINER
TECHNOLOGY CENTER 2600